

Abstract Submitted
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Nanocoax arrays via NIL for high resolution sensing applications¹

BINOD RIZAL, PATRICK JAMIESON, SVET SIMIDJIYSKI, HUAIZHOU ZHAO, DONG CAI, STEPHEN SHEPARD, THOMAS C. CHILES, MICHAEL J. NAUGHTON, Boston College — We have used nanoimprint lithography to fabricate nanocoax array-based chemical sensors, starting from SU-8 polymer replicas of silicon nanopillars. Nanocoaxes are formed by metalizing the polymer pillars, followed by oxide dielectric coating and outer metal deposition, and a polymer filling for stabilization. Chemical mechanical polishing and reactive ion etching were then used to open the ends of the coaxes and form coaxial cavity (with a nanoporous component) structures, respectively. Adsorption of water and organic solvent molecules into the coax annuli caused significant changes to the complex impedance of the coaxial capacitor array ($\Delta C/C > 100\%$ for 50% relative humidity air). Impedance measurements with such coaxial nanocavity arrays thus provide highly sensitive and selective information for molecular detection, with ultimate sensitivity below 1 ppb, or $\sim 1 \mu\text{g}/\text{m}^3$.

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Michael J. Naughton
Boston College

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